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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/528,196	03/17/2005	1733	1150	000023-062		25	1

CONFIRMATION NO. 7017

CORRECTED FILING RECEIPT



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21839

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**Assignment For Published Patent Application**

Mitsui Chemicals, Inc., Tokyo, Japan and Sharp Kabushiki Kaisha, Osaka-Shi Osaka, JAPAN

**Power of Attorney:** The patent practitioners associated with Customer Number 21839.

**Domestic Priority data as claimed by applicant**

This application is a 371 of PCT/JP03/11973 09/19/2003

**Foreign Applications**

JAPAN 2002-273452 09/19/2002

**If Required, Foreign Filing License Granted:** 10/31/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/528,196**

**Projected Publication Date:** Not Applicable

**Non-Publication Request:** No

**Early Publication Request:** No

**Title**

Liquid crystal sealing agent composition and manufacturing method of liquid crystal display panel using the same

**Preliminary Class**

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